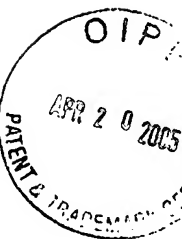


PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Application No. : 10/696,432 Confirmation No. 6825  
Applicant : Ying-Lang Wang  
Filed : October 29, 2003  
TC/A.U. : 2813

Title : CMP Process Leaving No Residual Oxide Layer or Slurry  
Particles

Docket No. : N1085-90131 (TS01-167CB)  
Customer No. : 08933

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

CERTIFICATE OF MAILING,  
37 C.F.R. §1.8(a)

I certify that this correspondence and the  
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for Patents, PO Box 1450, Alexandria, Virginia  
22313-1450

*Richard A. Paikoff*  
Richard A. Paikoff, Reg. No. 34,892

11-2-05  
Date

AMENDMENT AND RESPONSE

Sir:

In response to the Office Action of December 28, 2004, please amend the above-  
identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2  
of this paper.

**Remarks** begin on page 4 of this paper.